

NDIA Armaments Division 2016

Armament Systems Forum

S&T Needs and GAPsHow to Better Communicate

Panel Discussion

Armament Division
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Broden Resource Solutions LLC





S&T Needs and GAP's How to Better Communicate

PANEL MEMBERS

- Dave Broden, Panel Moderator
 - President Broden Resource Solutions LLC, Armament Division Chair
- Panelists:
 - Mr. Joe Pelino, US Army ARDEC
 - Mr. Mike Till, NSWC Dahlgren
 - Mr. Joe Buzzett, General Dynamics-OTS
- Attendee Participation:
 - Participation and Dialogue Enhances Panel Effectiveness and Value
 - Provide Observations, Comments, and Questions

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S&T Needs and GAP's Better Communication The Situation

- S&T Needs and GAPs Constantly Evolve—Require Focus and Attention
- Government R&D Centers and Industrial Base S&T Initiatives Are Focus to Address Timely and Relevant Responses to Needs and GAPs
- Communications Clarity and Timeliness is Key to Enable Response
 - Link User Community with:
 - Government R&D Centers
 - Industrial Base
- Both Government and Industrial Base Must Establish and Maintain Responsive "State of Art" S&T Capability
- <u>Establishing and Maintaining "Open and Clear Communications" is</u> <u>Priority to Ensure Timely and Relevant Response to Needs and GAPs</u>





S&T Needs and GAP's Panel Objectives

Assess S&T Needs and GAPs Evolving Topics and Awareness

Discuss Communication of Needs and GAP's User Community to DOD S&T Centers—Industry

Overview Industry Approach to S&T Investment Initiative Communication to Government

Address Barriers and Challenges for Communication

Identify Approaches to Improve Communication and Sharing

Highlight Benefits of Improved S&T Needs and GAPs Awareness

Confirm Incentives for Improvement

Impact on S&T Investments and Product Development





S&T Needs and GAP's Better Communication Why Knowing S&T Needs and GAPs is Important!!

Government View:

- Enables S&T Investment Strategies and Funding Priorities
- Facilitates Addressing Priority Actions
- Links S&T to JCIDS and Evolving Requirements
- Addresses Plans for Industry S&T Contracts

Industry View:

- Key Element of Future Opportunities Vision
- Enables Shaping of IR&D and Related Business Strategies
- Identifies Opportunity for Technology Driven Innovation Initiatives
- Facilitates "State of Art" S&T Capabilities and Application TRL
- Reduces Timeline for Requirements, S&T, and Development





S&T Needs and GAP's Topics for Discussion

- Communication
 — "What, How, When, Who"
- Needs and GAP Awareness
- Technology Evolution—Speed of Technology Change
- Requirements Process—Complexity and Length of Time
- Ensuring User Agencies and R&D Centers are Aware of Industry "State of Art"
- Ensuring Industry Links to R&D Center Relevant S&T Activities
- Development of Product using Timely "State of Art"
- Requirement Pull vs. Technology Push
- <u>Timely and Relevant Industry/Government Response to Needs/GAPS</u>





S&T Needs and GAP's Government Agency Awareness

• Effective:

- JCIDS Process
- User Agency to R&D Center Links
- "Operational Feedback"

• Limitations:

- May be Limited to Specific Needs/Requirements
- Funding Constraints

• Opportunities:

- Increase User Participation in S&T Plans and Activities
- Ensure User Involvement in NAC/DOTC Plans/Projects





S&T Needs and GAP's Industry Awareness

• Effective:

- Industry Day Events at User Locations
- NAC/DOTC Industry Days
- Industry Meetings with User or R&D Centers

Limitations:

- Discussion Constrained by Government Data Exchange
- User Comments re: Deployed Systems not Shared due to concern industry may consider comments as opportunity vs. data for consideration.
- Proprietary Information
- Competition Factors

Opportunities:

- Facilitate Industry Dialogue at all User and R&D Centers
- Earlier and Incremental Release of Needs/GAP's
- Enable or Modify JCIDS to Facilitate Industry Dialogue Earlier in the Process





S&T Needs and GAP's Requirements Pull vs. Technology Push

Requirements Pull:

- JCIDS Process
- Technology Driven by Specific Requirements
- Often Linked to Demonstrated TRL Level
- Tends to Focus on Existing or Proven Technology

Technology Push:

- Open to Innovation in S&T not Constrained to Requirements
- Not Directly Tied to TRL Level
- Enables "State of Art" Technology Application
- Leverages Industry Innovation
 - "DOD Silicon Valley Initiative"
 - Commercial Technology Applied to DOD Products
- Concern: Sometimes Not Accepted Due to Not Linked to JCIDS etc.

Discussion: Achieving Balance of Both Pull and Push





S&T Needs and GAP's Innovation Thru Commercial Technology Leveraging

Situation:

- Industrial Base (Both DOD Related and Commercial) has Unique and "State of Art" S&T Capability for DOD Application.
- Leveraging Commercial S&T for DOD Application May be Limited by Lack of Communication Awareness of S&T Needs and GAP's
- Commercial Focused Industry May Hold S&T Activity "Tightly"

• Status:

 DOD "Silicon Valley Initiative" Established to Facilitate/Encourage Use of "State of Art" Commercial S&T

Question:

- Are Needs and GAPs Accessible to Commercial Industry to Enable Links to Leverage Unique S&T Effectively and Timely?
- How can Communications be Facilitated with DOD Community and with DOD Industrial Base?





S&T Needs and GAP's Communication Challenges

Government:

- Competition Procurement Guidelines
- Public Release Constraints
- Timely Communication with Clarity of Statements
- Clarity of S&T Response Plans

• Industry:

- Attention to Needs and GAPs
- Linking Industry S&T Strategies and Investment to Need/GAP Priorities
- Competition Strategies and Impact
- Proprietary Information and Data
- Patents and Related Ownership
- Ensuring Focused, Relevant, and TRL Ready S&T Capability





S&T Needs and GAP's Focus Outcomes

- Needs and GAP's Communicated with Specific Link to Requirements
- Expand Dialogue Regarding "Technology Driven" Technology/Application
- Relaxed Constraints for Industrial Base Dialogue with User/R&D Centers
- Industry Awareness Guides Investment Initiatives in "State of Art"
- Balance Enabling of Requirements Pull vs. Technology Push
- Rapid Response to Critical Path Actions



S&T Needs and GAP's Communication Process Improvements

- Evolve Simple Process for Listing S&T Needs and Priorities
- Provide Focal Points
- Provide List at Regular Schedule (e.g. twice per year?)
- Provide Simple Feedback Loop for R&D Centers and Industrial Base to identify available relevant capability
 - Requirement Pull
 - Technology Push
- Communicate through:
 - 1. NDIA Forums etc.
 - 2. NAC/DOTC
 - 3. During Industry Days (Ft. Benning, NSWC-Dahlgren, Eglin AFB etc.)
- Other Limited Access Methods





S&T Needs and GAP's Better Communication Benefits

- 1. Assured Government and Industry Awareness of Needs/GAP's
- 2. Improved Understanding of Evolving Requirements
- 3. Improved Link of Needs/GAPs to Requirements
- 4. Opportunity for Increased Awareness of Industry/Government Relevant S&T "State of Art" Activity and Approach
 — "What is Available?"
- 5. Improved (Shorter) Response Time to Address Needs/GAPs
- 6. Product Development Applies "State of Art" vs. Past Technology
- 7. Pay-off For S&T Investments at Earlier Date
 - Government Lab S&T Investment Application
 - Industry Incentives for IR&D and Related Investments
- 8. Opportunity for Priority of NAC/DOTC Projects





S&T Needs and GAP's Better Communication Summary- Bottom Line

- S&T Needs and GAP *Awareness Enables* Focused and Timely "State of Art" Response to User Capability Objectives
- *Timely and Clarity of Communication* Ensures Government and Industry Strategies Linked and Focused to Priorities.
- Increased Linkage of User, R&D Centers with Industrial Base Partners Will Offer Innovative Responses
- Benefit Realized Include:
 - Expanded Application of Relevant Commercial Technology
 - Investment Strategies Linked to Needs/GAPs
 - Ensure JCID Process Consideration of "State of Art"
 - Timely Readiness of TRL Level for Application TRL>5
 - Program Cost and Schedule Benefits/Risk Reduction
 - Contract Opportunities for Industry

Initiatives Focused to Improved S&T Needs and GAPs Communication is Key to Evolving Technology Leadership

